TRADEMARK ASSIGNMENT

Electronic Version v1.1
Stylesheet Version v1.1

SUBMISSION TYPE:	NEW ASSIGNMENT
NATURE OF CONVEYANCE:	RELEASE BY SECURED PARTY

CONVEYING PARTY DATA

Name	Formerly	Execution Date	Entity Type
ENTERPRISE PARTNERS VI, L.P.		10/20/2011	LIMITED PARTNERSHIP: DELAWARE
KPCB HOLDINGS, INC., as Nominee		10/20/2011	CORPORATION: CALIFORNIA
TREX ENTERPRISES CORPORATION		10/20/2011	CORPORATION: CALIFORNIA

RECEIVING PARTY DATA

Name:	OPHTHONIX, INC.
Street Address:	1491 Poinsettia Avenue
City:	Vista
State/Country:	CALIFORNIA
Postal Code:	92081
Entity Type:	CORPORATION: DELAWARE

PROPERTY NUMBERS Total: 22

Property Type	Number	Word Mark
Registration Number:	3946032	!.ZON
Registration Number:	3747847	IPRINT
Registration Number:	3188278	IZON
Registration Number:	3848128	IZON
Registration Number:	3785122	I·ZON HIGH RESOLUTION LENSES
Registration Number:	3195116	ME, MYSELF AND EYE
Registration Number:	2925566	OPHTHONIX
Registration Number:	2995471	OPHTHONIX
Registration Number:	3127221	OPHTHONIX
Registration Number:	3108248	OPHTHONIX
Registration Number:	3273499	OPHTHONIX

CH $565.00 3946032

Registration Number:	3379275	OPHTHONIX
Registration Number:	3866649	POWERED BY IPRINT
Registration Number:	3482599	PUBLICIZE
Registration Number:	3858700	WOW
Registration Number:	3199308	Z VIEW
Registration Number:	3319911	Z·V!EW
Serial Number:	78848390	!.ZON CUSTOMIZED PROGRESS!VES
Serial Number:	77861790	INSTALENS
Serial Number:	77698196	IZONIK
Serial Number:	77872400	NEAR, FAR AND IN-BETWEEN
Serial Number:	85081848	WOW

CORRESPONDENCE DATA

Fax Number: (858)550-6420
Phone: 858-550-6403
Email: erin.obrien@cooley.com

Correspondence will be sent to the e-mail address first; if that is unsuccessful, it will be sent via US Mail.

Correspondent Name: Erin O'Brien
Address Line 1: c/o Cooley LLP
Address Line 2: 4401 Eastgate Mall
Address Line 4: San Diego, CALIFORNIA 92121

ATTORNEY DOCKET NUMBER:	300738-109 OPHTHONIX
NAME OF SUBMITTER:	Erin O'Brien
Signature:	/Erin O'Brien/
Date:	10/21/2011

Total Attachments: 17
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RELEASE OF SECURITY INTEREST

This Release of Security Interest is made as of October 20, 2011, by each of the undersigned (each a "Lender" and collectively the "Lenders") in favor of OPHTHONIX, INC., a Delaware corporation ("Company"), with its principal place of business located at 1491 Poinsettia Avenue, Vista, CA 92081.

Recitals

WHEREAS, Company granted to Lenders a security interest in the patents and trademarks described on Exhibits A and B attached hereto, respectively (collectively, the "Intellectual Property"), under an Intellectual Property Security Agreement dated as of June 2, 2011 (the "Security Agreement"), and recorded with the US Patent and Trademark Office as set forth on Exhibits A and B.

WHEREAS, Company has no outstanding obligations to Lenders under the terms of the Security Agreement and each Lender agrees to release its security interest in the Intellectual Property.

Agreement

Now therefore, each Lender agrees that it terminates and releases its security interest in the Intellectual Property and reassigns to Company, without warranty or recourse, all interest of such Lender in the Intellectual Property.

Each Lender authorizes the Company, or its agent, to terminate any financing statement on file in favor of such Lender.

LENDERS:

ENTERPRISE PARTNERS VI, L.P.
By: Enterprise Management Partners VI, LLC,
Its General Partner

By: _____
Name: ~~Andrew E. Senyei, M.D.~~ Carl Eibl, Managing Partner
2223 Avenida de la Playa, Suite 300
La Jolla, CA 92037

KPCB HOLDINGS, INC., as Nominee
c/o Kleiner Perkins Caufield & Byers

By: _____
Name: Joseph S. Lacob, Senior Vice President
2750 Sand Hill Road
Menlo Park, CA 94025

TREX ENTERPRISES CORPORATION

By: _____
Name: Kenneth Y. Tang, Chairman and CEO
10455 Pacific Center Court
San Diego, CA 92121

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LENDERS:

ENTERPRISE PARTNERS VI, L.P.
By: Enterprise Management Partners VI, LLC,
Its General Partner

By:_____
Name: Andrew E. Senyei, M.D., Managing Partner
2223 Avenida de la Playa, Suite 300
La Jolla, CA 92037

KPCB HOLDINGS, INC., as Nominee
c/o Kleiner Perkins Caufield & Byers

By: Joseph S Lacob
Name: Joseph S. Lacob, Senior Vice President
2750 Sand Hill Road
Menlo Park, CA 94025

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By:_____
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ENTERPRISE PARTNERS VI, L.P.
By: Enterprise Management Partners VI, LLC,
Its General Partner

By:_____
Name: Andrew E. Senyei, M.D., Managing Partner
2223 Avenida de la Playa, Suite 300
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KPCB HOLDINGS, INC., as Nominee
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By:_____
Name: Joseph S. Lacob, Senior Vice President
2750 Sand Hill Road
Menlo Park, CA 94025

TREX ENTERPRISES CORPORATION

By:_____
Name: Kenneth Y. Tang, Chairman and CEO
10455 Pacific Center Court
San Diego, CA 92121

EXHIBIT A

Patents

#	Title of Invention	Issue No.	Application Type
OPH.001A	Custom Eyeglass Manufacturing Method	6,682,195	Regular US
OPH.004A	Eyeglass Manufacturing Method Using Variable Index Layer	6,712,466	Regular US
OPH.003A	Apparatus And Method For Determining Objective Refraction Using Wavefront Sensing	6,761,454*	Regular US
OPH.002A	System And Method For Wavefront Measurement	6,781,681	Regular US
OPH.013A	Wavefront Aberrator And Method Of Manufacturing	6,813,082	Regular US
OPH.011A	Optical Elements And Methods For Making Thereof	6,836,371	Regular US
OPH.004C1	Eyeglass Manufacturing Method Using Variable Index Layer	6,840,619*	Regular US (C)
OPH.011DV1	Optical Elements And Methods For Making Thereof	6,934,088	Regular US (DIV)
OPH.004C1C1	Eyeglass Manufacturing Method Using Variable Index Layer	6,942,339	Regular US (C)(C)
OPH.011DV2	Optical Elements And Methods For Making Thereof	6,976,641	Regular US (DIV)
OPH.013DV1	Wavefront Aberrator And Method Of Manufacturing	6,989,938	Regular US (DIV)
OPH.004C1DV1	Eyeglass Manufacturing Method Using Variable Index Layer	7,021,764	Regular US (C)(DIV)
OPH.002CP1	System And Method For Wavefront Measurement	7,034,949	Regular US (CIP)
OPH.003C1	Apparatus And Method For Determining Objective Refraction Using Wavefront Sensing	7,114,808	Regular US (C)
OPH.044A	Eyeglass Dispensing Method	7,188,950	Regular US
OPH.013CP2	Apparatus And Method Of Fabricating A Compensating Element For Wavefront Correction Using Spatially Localized Curing Of Resin Mixtures	7,217,375	Regular US (CIP)
OPH.023A	System For Manufacturing An Optical Lens	7,234,810	Regular US
OPH.004C1C3	Eyeglass Manufacturing Method Using Variable Index Layer	7,249,847	Regular US (C)
OPH.013CP1	Apparatus And Method Of Correcting Higher-Order Aberrations Of The Human Eye	7,293,871	Regular US (CIP)
OPH.031A	Monomers And Polymers For Optical Elements	7,371,804	Regular US
OPH.011CP1	Optical Elements And Methods For Making Thereof	7,420,743	Regular US (CIP)
OPH.024A	Ophthalmic Diagnostic Instrument	7,425,067	Regular US
OPH.001CP1	Custom Eyeglass Manufacturing Method	7,434,931	Regular US

#	Title of Invention	Issue No.	Application Type
			(CIP)
OPH.002CP1A	System And Methods For Wavefront Measurement	7,440,115	Regular US (CIP)(C)
OPH.038A	Apparatus And Method For Determining Sphere And Cylinder Components Of Subjective Refraction Using Objective Wavefront Measurement	7,461,938	Regular US
OPH.003HC1C2	Method For Determining Objective Refraction Using Wavefront Sensing	7,490,940	Regular US
OPH.023C1	System For Manufacturing An Optical Lens	7,497,573	Regular US
OPH.004C1C4	Eyeglass Manufacturing Method Using Variable Index Layer	7,503,651	Regular US
OPH.044C1	Eyeglass Dispensing Method	7,568,799	Regular US
OPH.004C1C7	Vision In Macular Degeneration Patients	7,588,333	Regular US
OPH.026C1	Lensometers And Wavefront Sensors And Methods Of Measuring Aberration	7,659,971	Regular US
OPH.013DV1A	Apparatus And Method Of Correcting Higher-Order Aberrations Of The Human Eye	7,695,134	Regular US
OPH.047A	High-Order Aberration Correction For Optimization Of Human Visual Function	7,697,212	Regular US
OPH.048A	Materials And Methods For Producing Lenses	7,701,641	Regular US
OPH.039DV1	Method For Stabilizing Refractive Index Profiles Using Polymer Mixtures	7,772,297	Regular US
OPH.031C1	Monomers And Polymers For Optical Elements	7,821,719	Regular US
OPH.038C1	Apparatus And Method For Determining Sphere And Cylinder Components Of Subjective Refraction Using Objective Wavefront Measurement	7,824,033	Regular US
OPH.066A	Customized Z-Lens Design Program	7,832,863	Regular US
OPH.001A1	Custom Eyeglass Manufacturing Method	7,845,797	Regular US
OPH.004C1C2	Eyeglass Manufacturing Method Using Variable Index Layer	7,857,466	Regular US
OPH.024ADV1	Ophthalmic Diagnostic Instrument	7,909,461	Regular US
OPH.074A	Methods And Lenses For Correction Of Chromatic Aberration	7,918,555	Regular US
OPH.004C1C6	Eyeglass Manufacturing Method Using Variable Index Layer	7,931,368	Regular US
OPH.004VAU	Eyeglass Manufacturing Method Using Variable Index Layer	2002340292	Australian Patent
OPH.002QAU	Systems And Methods For Wavefront Measurement	2002362137	Australian Patent
OPH.001VAU	Custom Eyeglass Manufacturing Method	2002367536	Australian Patent
OPH.003HAU	Apparatus And Method For Objective Characterization Of Vision Based On Wavefront	2003213122	Australian Patent

#	Title of Invention	Issue No.	Application Type
	Sensing		
OPH.011VAU	Optical Elements And Methods For Making Thereof	2003247630	Australian Patent
OPH.013HAU	Apparatus And Method Of Fabricating A Compensating Element For Wavefront Correction Using Spatially Localized Curing Of Resin Mixtures	2003265955	Australian Patent
OPH.024VAU	Ophthalmic Binocular Wavefront Measurement System	2004291042	Australian Patent
OPH.023VAU	System For Manufacturing An Optical Lens	2004292165	Australian Patent
OPH.032VAU	Method Of Manufacturing An Optical Lens	2005282403	Australian Patent
OPH.024VCN	Ophthalmic Binocular Wavefront Measurement System	200480036926.0	Chinese Patent
OPH.048VCN	Materials And Methods For Producing Lenses	200780009729.3	Chinese Patent
OPH.004VEP	Eyeglass Manufacturing Method Using Variable Index Layer	1439946**	European Patent
OPH.004VEPAT	Eyeglass Manufacturing Method Using Variable Index Layer	1439946 Abandoned	Austrian Patent
OPH.004VEPBE	Eyeglass Manufacturing Method Using Variable Index Layer	1439946	Belgian Patent
OPH.004VEPCH	Eyeglass Manufacturing Method Using Variable Index Layer	1439946 Abandoned	Swiss Patent
OPH.004VEPDE	Eyeglass Manufacturing Method Using Variable Index Layer	1439946 Abandoned	German Patent
OPH.004VEPES	Eyeglass Manufacturing Method Using Variable Index Layer	1439946 Abandoned	Spanish Patent
OPH.004VEPFI	Eyeglass Manufacturing Method Using Variable Index Layer	1439946 Abandoned	Finnish Patent
OPH.004VEPFR	Eyeglass Manufacturing Method Using Variable Index Layer	1439946 Abandoned	French Patent
OPH.004VEPGB	Eyeglass Manufacturing Method Using Variable Index Layer	1439946 Abandoned	British Patent
OPH.004VEPIE	Eyeglass Manufacturing Method Using Variable Index Layer	1439946 Abandoned	Irish Patent
OPH.004VEPIT	Eyeglass Manufacturing Method Using Variable Index Layer	1439946 Abandoned	Italian Patent
OPH.004VEPNL	Eyeglass Manufacturing Method Using Variable Index Layer	1439946 Abandoned	Dutch Patent
OPH.004VEPSE	Eyeglass Manufacturing Method Using Variable Index Layer	1439946 Abandoned	Swedish Patent
OPH.013QEP	Apparatus And Method Of Correcting Higher-Order Aberrations Of The Human Eye	1535104	European Patent

#	Title of Invention	Issue No.	Application Type
OPH.013QAT	Apparatus And Method Of Correcting Higher-Order Aberrations Of The Human Eye	1535104	Austrian Patent
OPH.013QCH	Apparatus And Method Of Correcting Higher-Order Aberrations Of The Human Eye	1535104	Swiss Patent
OPH.013QDE	Apparatus And Method Of Correcting Higher-Order Aberrations Of The Human Eye	1535104	German Patent
OPH.013QES	Apparatus And Method Of Correcting Higher-Order Aberrations Of The Human Eye	1535104	Spanish Patent
OPH.013QET	Apparatus And Method Of Correcting Higher-Order Aberrations Of The Human Eye	1535104	Italian Patent
OPH.013QFR	Apparatus And Method Of Correcting Higher-Order Aberrations Of The Human Eye	1535104	French Patent
OPH.013QGB	Apparatus And Method Of Correcting Higher-Order Aberrations Of The Human Eye	1535104	British Patent
OPH.013QIE	Apparatus And Method Of Correcting Higher-Order Aberrations Of The Human Eye	1535104	Irish Patent
OPH.015VEP	Apparatus And Method For Curing Of UV-Protected UV-Curable Monomer And Polymer Mixtures	1625425 Abandoned	European Patent
OPH.015VDE	Apparatus And Method For Curing Of UV-Protected UV-Curable Monomer And Polymer Mixtures	1625425 Abandoned	German Patent
OPH.015VFR	Apparatus And Method For Curing Of UV-Protected UV-Curable Monomer And Polymer Mixtures	1625425 Abandoned	French Patent
OPH.004VEPD1	Eyeglass Manufacturing Method Using Variable Index Layer	1808287	European Patent
OPH.004VEPD1AT	Eyeglass Manufacturing Method Using Variable Index Layer	1808287	Austrian Patent
OPH.004VEPD1CH	Eyeglass Manufacturing Method Using Variable Index Layer	1808287	Swiss Patent
OPH.004VEPD1DE	Eyeglass Manufacturing Method Using Variable Index Layer	1808287	German Patent
OPH.004VEPD1ES	Eyeglass Manufacturing Method Using Variable Index Layer	1808287	Spanish Patent
OPH.004VEPD1FI	Eyeglass Manufacturing Method Using Variable Index Layer	1808287	Finnish Patent
OPH.004VEPD1FR	Eyeglass Manufacturing Method Using Variable Index Layer	1808287	French Patent
OPH.004VEPD1GB	Eyeglass Manufacturing Method Using Variable Index Layer	1808287	British Patent
OPH.004VEPD1IE	Eyeglass Manufacturing Method Using Variable Index Layer	1808287	Irish Patent
OPH.004VEPD1IT	Eyeglass Manufacturing Method Using Variable Index Layer	1808287	Italian Patent

#	Title of Invention	Issue No.	Application Type
OPH.004VEPD1NL	Eyeglass Manufacturing Method Using Variable Index Layer	1808287	Dutch Patent
OPH.004VEPD1SE	Eyeglass Manufacturing Method Using Variable Index Layer	1808287	Swedish Patent
OPH.023VIL	System For Manufacturing An Optical Lens	175496	Israeli Patent
OPH.003HJP	Apparatus And Method For Determining Subjective Responses Using Objective Characterization Of Vision Based On Wavefront Sensing	4308669	Japanese Patent
OPH.002QJP	Systems And Methods For Wavefront Measurement	4323955	Japanese Patent
OPH.004VJP	Eyeglass Manufacturing Method Using Variable Index Layer	4349905	Japanese Patent
OPH.001VJP	Custom Eyeglass Manufacturing Method	4361806	Japanese Patent
OPH.011VJP	Optical Elements And Methods For Making Thereof	4436755	Japanese Patent
OPH.024VJP	Ophthalmic Binocular Wavefront Measurement System	4668204	Japanese Patent
OPH.044VKO	Eyeglass Manufacturing Method	10-0957239	South Korean Patent
OPH.001VEP	Custom Eyeglass Manufacturing Method	Filed	European Patent Convention
OPH.001VPC	Custom Eyeglass Manufacturing Method	Filed	PCT
OPH.001QPC	Custom Eyeglass Manufacturing Method	Filed	PCT
OPH.001QEP	Custom Eyeglass Manufacturing Method	Filed	European Patent Convention
OPH.001QJP	Custom Eyeglass Manufacturing Method	Filed	Japan
OPH.002QPC	System And Method For Wavefront Measurement	Inactive	PCT
OPH.002QEP	System And Method For Wavefront Measurement	Filed	European Patent Convention
OPH.003HC1	Apparatus And Method For Determining Responses Using Objective Characterization Of Vision Based On Wavefront Sensing	Inactive	US
OPH.003HC1C	Apparatus And Method For Determining Subjective Responses Using Objective Characterization Of Vision Based On Wavefront Sensing	Abandoned	US
OPH.003HC1C3	Apparatus And Method For Determining Objective Refraction Using Wavefront Sensing	Abandoned	US
OPH.003HPC	Apparatus And Method For Determining Subjective Responses Using Objective Characterization Of Vision Based On Wavefront Sensing	Inactive	PCT

#	Title of Invention	Issue No.	Application Type
OPH.003HEP	Apparatus And Method For Objective Characterization Of Vision Based On Wavefront Sensing	Filed	European Patent Convention
OPH.004C1C5	Eyeglass Manufacturing Method Using Variable Index Layer	Abandoned	US
OPH.004C1C9	Eyeglass Manufacturing Method Using Variable Index Layer	Filed	US
OPH.004VPC	Eyeglass Manufacturing Method Using Variable Index Layer	Inactive	PCT
OPH.004VAUD1	Eyeglass Manufacturing Method Using Variable Index Layer	Filed	Australia
OPH.011C1	Optical Elements And Methods For Making Thereof	Abandoned	US
OPH.011VPC	Optical Elements And Methods For Making Thereof	Inactive	PCT
OPH.011VEP	Optical Elements And Methods For Making Thereof	Filed	European Patent Convention
OPH.011VIL	Optical Elements And Methods For Making Thereof	Filed	Israel
OPH.011QPC	Optical Elements And Methods For Making Thereof	Inactive	PCT
OPH.013C4	Apparatus And Method Of Fabricating A Compensating Element For Wavefront Correction Using Spatially Localized Curing Of Resin Mixtures	Abandoned	US
OPH.013C4C1	Apparatus And Method Of Fabricating A Compensating Element For Wavefront Correction Using Spatially Localized Curing Of Resin Mixtures	Filed	US
OPH.013CP4	Apparatus And Method Of Fabricating An Ophthalmic Lens For Wavefront Correction Using Spatially Localized Curing Of Photo-Polymerization Materials	Abandoned	US
OPH.013CP4A	Apparatus And Method Of Fabricating An Ophthalmic Lens For Wavefront Correction Using Spatially Localized Curing Of Photo-Polymerization Materials	Abandoned	US
OPH.013HPC	Apparatus And Method Of Fabricating A Compensating Element For Wavefront Correction Using Spatially Localized Curing Of Resin Mixtures	Inactive	PCT
OPH.013HEP	Apparatus And Method Of Fabricating A Compensating Element For Wavefront Correction Using Spatially Localized Curing Of Resin Mixtures	Abandoned	European Patent Convention
OPH.013HIL	Apparatus And Method Of Fabricating A Compensating Element For Wavefront Correction Using Spatially Localized Curing Of Resin Mixtures	Filed	Israel
OPH.013HJP	Apparatus And Method Of Fabricating A	Abandoned	Japan

#	Title of Invention	Issue No.	Application Type
	Compensating Element For Wavefront Correction Using Spatially Localized Curing Of Resin Mixtures		
OPH.013QPC	Apparatus And Method Of Correcting Higher-Order Aberrations Of The Human Eye	Inactive	PCT
OPH.013QAU	Apparatus And Method Of Correcting Higher-Order Aberrations Of The Human Eye	Allowed	AU
OPH.013QEP1	Apparatus And Method Of Correcting Higher-Order Aberrations Of The Human Eye	Abandoned	European Patent Convention
OPH.013QJP	Apparatus And Method Of Correcting Higher-Order Aberrations Of The Human Eye	Filed	Japan
OPH.013VPC	Apparatus And Method Of Fabricating An Ophthalmic Lens For Wavefront Correction Using Spatially Localized Curing Of Photo-Polymerization Materials	Inactive	PCT
OPH.013VAU	Apparatus And Method Of Fabricating An Ophthalmic Lens For Wavefront Correction Using Spatially Localized Curing Of Photo-Polymerization Materials	Abandoned	Australia
OPH.013VEP	Apparatus And Method Of Fabricating An Ophthalmic Lens For Wavefront Correction Using Spatially Localized Curing Of Photo-Polymerization Materials	Abandoned	European Patent Convention
OPH.013VJP	Apparatus And Method Of Fabricating An Ophthalmic Lens For Wavefront Correction Using Spatially Localized Curing Of Photo-Polymerization Materials	Abandoned	Japan
OPH.015A	Apparatus And Method For Curing Of UV-Protected And UV-Curable Monomers And Polymer Mixtures	Abandoned	US
OPH.015C1	Apparatus And Method For Curing Of UV-Protected And UV-Curable Monomers And Polymer Mixtures	Abandoned	US
OPH.015VPC	Apparatus And Method For Curing Of UV-Protected UV-Curable Monomer And Polymer Mixtures	Inactive	PCT
OPH.015VAU	Apparatus And Method For Curing Of UV-Protected UV-Curable Monomer And Polymer Mixtures	Abandoned	Australia
OPH.015VJP	Apparatus And Method For Curing Of UV-Protected UV-Curable Monomer And Polymer Mixtures	Abandoned	Japan
OPH.023C2	System For Manufacturing An Optical Lens	Filed	US
OPH.023VPC	System For Manufacturing An Optical Lens	Inactive	PCT
OPH.023VEP	System For Manufacturing An Optical Lens	Filed	European Patent Convention

#	Title of Invention	Issue No.	Application Type
OPH.023VJP	System For Manufacturing An Optical Lens	Filed	Japan
OPH.024ADV2	Ophthalmic Binocular Wavefront Measurement System	Filed	US
OPH.024VPC	Ophthalmic Binocular Wavefront Measurement System	Inactive	PCT
OPH.024VEP	Ophthalmic Binocular Wavefront Measurement System	Filed	European Patent Convention
OPH.024VKO	Ophthalmic Binocular Wavefront Measurement System	Allowed	South Korea
OPH.024VMX	Ophthalmic Binocular Wavefront Measurement System	Filed	Mexico
OPH.025A	System And Method For Analyzing Wavefront Aberrations	Abandoned	US
OPH.025DV1	System And Method For Analyzing Wavefront Aberrations	Allowed	US
OPH.025VPC	System And Method For Analyzing Wavefront Aberrations	Inactive	PCT
OPH.025VAU	System And Method For Analyzing Wavefront Aberrations	Filed	Australia
OPH.025VEP	System And Method For Analyzing Wavefront Aberrations	Filed	European Patent Convention
OPH.025VIL	System And Method For Analyzing Wavefront Aberrations	Filed	Israel
OPH.025VJP	System And Method For Analyzing Wavefront Aberrations	Filed	Japan
OPH.026A	Lensometers And Wavefront Sensors And Methods Of Measuring Aberration (Lensometer)	Abandoned	US
OPH.026VPC	Lensometers And Wavefront Sensors And Methods Of Measuring Aberration	Inactive	PCT
OPH.026VEP	Lensometers And Wavefront Sensors And Methods Of Measuring Aberration	Filed	European Patent Convention
OPH.026VJP	Lensometers And Wavefront Sensors And Methods Of Measuring Aberration	Filed	Japan
OPH.31C2	Monomers And Polymers For Optical Elements	Filed	US
OPH.031CIP1	Custom Monomers And Polymers For Spectacle Lenses	Filed	US
OPH.031CIP1VPC	Custom Monomers And Polymers For Spectacle Lenses	Abandoned	PCT
OPH.031CIP1VAU	Custom Monomers And Polymers For Spectacle Lenses	Abandoned	Australia
OPH.031CIP1VCA	Custom Monomers And Polymers For Spectacle Lenses	Abandoned	Canada

#	Title of Invention	Issue No.	Application Type
OPH.031CIP1VCN	Custom Monomers And Polymers For Spectacle Lenses	Abandoned	China
OPH.031CIP1VEP	Custom Monomers And Polymers For Spectacle Lenses	Abandoned	European Patent Convention
OPH.031CIP1VJP	Custom Monomers And Polymers For Spectacle Lenses	Abandoned	Japan
OPH.031CIP1VMX	Custom Monomers And Polymers For Spectacle Lenses	Abandoned	Mexico
OPH.031CIP2	Tinted Lenses That Correct For High Order Aberrations	Allowed	US
OPH.031CIP2VPC	Tinted Lenses That Correct For High Order Aberrations	Inactive	PCT
OPH.031CIP2VAU	Tinted Lenses That Correct For High Order Aberrations	Filed	Australia
OPH.031CIP2VEP	Tinted Lenses That Correct For High Order Aberrations	Filed	European Patent Convention
OPH.031CIP2VJP	Tinted Lenses That Correct For High Order Aberrations	Filed	Japan
OPH.031VPC	Monomers And Polymers For Optical Elements	Inactive	PCT
OPH.031VAU	Monomers And Polymers For Optical Elements	Filed	Australia
OPH.031VEP	Monomers And Polymers For Optical Elements	Filed	European Patent Convention
OPH.031VIL	Monomers And Polymers For Optical Elements	Filed	Israel
OPH.031VJP	Monomers And Polymers For Optical Elements	Filed	Japan
OPH.031VKO	Monomers And Polymers For Optical Elements	Filed	South Korea
OPH.032A	Method Of Manufacturing An Optical Lens	Filed	US
OPH.032VPC	Method Of Manufacturing An Optical Lens	Inactive	PCT
OPH.032VEP	Method Of Manufacturing An Optical Lens	Filed	European Patent Convention
OPH.032VIL	Method Of Manufacturing An Optical Lens	Filed	Israel
OPH.032VJP	Method Of Manufacturing An Optical Lens	Filed	Japan
OPH.032VKO	Method Of Manufacturing An Optical Lens	Filed	South Korea
OPH.038VPC	Apparatus And Method For Determining Sphere And Cylinder Components Of Subjective Refraction Using Objective Wavefront Measurement	Inactive	PCT
OPH.038C2	Apparatus And Method For Determining Sphere And Cylinder Components Of Subjective Refraction Using Objective Wavefront Measurement	Filed	US
OPH.039A	Method For Stabilizing Refractive Index Profiles Using Polymer Mixtures	Abandoned	US

#	Title of Invention	Issue No.	Application Type
OPH.039DV2	Method For Stabilizing Refractive Index Profiles Using Polymer Mixtures	Filed	US
OPH.039VPC	Method For Stabilizing Refractive Index Profiles Using Polymer Mixtures	Inactive	PCT
OPH.039VAU	Method For Stabilizing Refractive Index Profiles Using Polymer Mixtures	Abandoned	Australia
OPH.039VEP	Method For Stabilizing Refractive Index Profiles Using Polymer Mixtures	Abandoned	European Patent Convention
OPH.039VIL	Method For Stabilizing Refractive Index Profiles Using Polymer Mixtures	Abandoned	Israel
OPH.039VJP	Method For Stabilizing Refractive Index Profiles Using Polymer Mixtures	Abandoned	Japan
OPH.039VKO	Method For Stabilizing Refractive Index Profiles Using Polymer Mixtures	Abandoned	South Korea
OPH.044C2	Eyeglass Dispensing Method	Filed	US
OPH.044VPC	Eyeglass Manufacturing Method	Inactive	PCT
OPH.044VAU	Eyeglass Manufacturing Method	Allowed	Australia
OPH.044VEP	Eyeglass Manufacturing Method	Filed	European Patent Convention
OPH.044VIL	Eyeglass Manufacturing Method	Allowed	Israel
OPH.044VJP	Eyeglass Manufacturing Method	Filed	Japan
OPH.47C1	High-Order Aberration Correction For Optimization Of Human Visual Function	Filed	US
OPH.047VPC	High-Order Aberration Correction For Optimization Of Human Visual Function	Inactive	PCT
OPH.047VAU	High-Order Aberration Correction For Optimization Of Human Visual Function	Filed	Australia
OPH.047VCA	High-Order Aberration Correction For Optimization Of Human Visual Function	Filed	Canada
OPH.047VCN	High-Order Aberration Correction For Optimization Of Human Visual Function	Filed	China
OPH.047VEP	High Order Aberration Correction For Optimization Of Human Visual Function	Filed	European Patent Convention
OPH.047VJP	High-Order Aberration Correction For Optimization Of Human Visual Function	Filed	Japan
OPH.48C1	Materials And Methods For Producing Lenses	Allowed	US
OPH.048VPC	Materials And Methods For Producing Lenses	Inactive	PCT
OPH.048VAU	Materials And Methods For Producing Lenses	Filed	Australia
OPH.048VCA	Materials And Methods For Producing Lenses	Filed	Canada
OPH.048VEP	Materials And Methods For Producing Lenses	Filed	European

#	Title of Invention	Issue No.	Application Type
			Patent Convention
OPH.048VJP	Materials And Methods For Producing Lenses	Filed	Japan
OPH.048VMX	Materials And Methods For Producing Lenses	Allowed	Mexico
OPH.066C1	Customized Z-Lens Design Program	Filed	US
OPH.066CP1	Method Of Designing Progressive Addition Lenses	Filed	US
OPH.066CPVPC	Method Of Designing Progressive Addition Lenses	Filed	PCT
OPH.066VPC	Customized Z-Lens Design Program	Filed	PCT
OPH.066VEP	Customized Z-Lens Design Program	Filed	European Patent Convention
OPH.066VJP	Customized Z-Lens Design Program	Filed	Japan
OPH.068A	Optical Elements With A Gap Between Two Lens Materials	Allowed	US
OPH.074VPC	Methods And Lenses For Correction Of Chromatic Aberration	Inactive	PCT
OPH.074AC1	Methods And Lenses For Correction Of Chromatic Aberration	Filed	US
OPH.075PR	Corrective Lenses Based On Wavefront Refraction For AMD Patients	Abandoned	US
OPH.077	Method Of Designing Progressive Addition Lenses	Filed	US

Lender's security interest recorded at the US Patent and Trademark Office on June 7, 2011 at Reel and Frame Number 026405/0745.

EXHIBIT B

Trademarks

Description	Serial/Application Number	Country	Registration/ Application Date	Status
!. ZON CUSTOMIZED PROGRESS!VES AND DESIGN	Serial No: 78/848,390	United States of America	App Date: 03/28/2006	Allowed - Intent to Use
20/HAPPY IS NOT VISION OPTIMIZED	Reg. No: 003847449	European Community	Reg Date: 08/12/2005	Registered
20/HAPPY IS NOT VISION OPTIMIZED	Reg. No: 5002164	Japan	Reg Date: 11/10/2006	Registered
INSTALENS	Reg. No: 005242409	European Community	Reg Date: 07/26/2007	Registered
INSTALENS	Reg. No: 5012986	Japan	Reg Date: 12/12/2006	Registered
INSTALENS	Reg. No: 554225	Switzerland	Reg Date: 01/16/2007	Registered
INSTALENS	Serial No: 1311784	Canada	App Date: 08/04/2006	Allowed
INSTALENS	Serial No: 77/861,790	United States of America	App Date: 10/30/2009	Allowed - Intent to Use
IPRINT	Reg. No: 005344155	European Community	Reg Date: 01/17/2008	Registered
IPRINT	Reg. No: 3,747,847	United States of America	Reg Date: 02/09/2010	Registered
IPRINT	Reg. No: 5037590	Japan	Reg Date: 03/30/2007	Registered
IPRINT	Reg. No: 554568	Switzerland	Reg Date: 01/23/2007	Registered
IPRINT	Serial No: 1317712	Canada	App Date: 09/14/2006	Filed
IZON	Reg. No: 004234027	European Community	Reg Date: 02/16/2006	Registered
IZON	Reg. No: 3,188,278	United States of America	Reg Date: 12/19/2006	Registered
IZON	Reg. No: 3,848,128	United States of America	Reg Date: 09/14/2010	Registered
IZON	Reg. No: 5049662	Japan	Reg Date: 05/25/2007	Registered
IZON	Reg. No: 551073	Switzerland	Reg Date: 10/13/2006	Registered
IZON	Serial No: 1242459	Canada	App Date: 12/22/2004	Allowed
IZON	Serial No: 2010041903	Japan	App Date: 05/27/2010	Filed
IZON (STYLIZED)	Reg. No: 004671434	European Community	Reg Date: 09/18/2006	Registered
IZON (STYLIZED)	Reg. No: 4953825	Japan	Reg Date: 05/19/2006	Registered
IZON (STYLIZED)	Serial No: 1275795	Canada	App Date: 10/06/2005	Filed
IZON (STYLIZED)	Serial No: 78/612,317	United States of America	App Date: 04/19/2005	Allowed - Intent to Use
IZON CUSTOMIZED PROGRESSIVES & DESIGN	Reg. No: 005318647	European Community	Reg Date: 08/30/2007	Registered
IZON CUSTOMIZED PROGRESSIVES & DESIGN	Reg. No: 5063887	Japan	Reg Date: 07/20/2007	Registered
IZON CUSTOMIZED PROGRESSIVES & DESIGN	Reg. No: 552064	Switzerland	Reg Date: 11/08/2006	Registered
IZON CUSTOMIZED PROGRESSIVES & DESIGN	Serial No: 1317100	Canada	App Date: 09/19/2006	Allowed

Description	Serial/Application Number	Country	Registration/ Application Date	Status
IZON EYEGLASSES ME MYSELF & EYE & EYE DESIGN	Reg. No: 004680641	European Community	Reg Date: 10/23/2006	Registered
IZON EYEGLASSES ME MYSELF & EYE & EYE DESIGN	Reg. No: 4962123	Japan	Reg Date: 06/16/2006	Registered
IZON HIGH RESOLUTION LENSES & DESIGN	Reg. No: 005858089	European Community	Reg Date: 03/27/2008	Registered
IZON HIGH RESOLUTION LENSES & DESIGN	Reg. No: 3,785,122	United States of America	Reg Date: 05/04/2010	Registered
IZON HIGH RESOLUTION LENSES & DESIGN	Reg. No: 5075539	Japan	Reg Date: 09/07/2007	Registered
IZON HIGH RESOLUTION LENSES & DESIGN	Reg. No: 560279	Switzerland	Reg Date: 07/16/2007	Registered
IZON HIGH RESOLUTION LENSES & DESIGN	Serial No: 1345094	Canada	App Date: 04/26/2007	Published
IZONIK	Reg. No: 004766754	European Community	Reg Date: 11/20/2006	Registered
IZONIK	Reg. No: 4943566	Japan	Reg Date: 04/07/2006	Registered
IZONIK	Serial No: 77/698,196	United States of America	App Date: 03/24/2009	Allowed - Intent to Use
ME, MYSELF AND EYE	Reg. No: 004679701	European Community	Reg Date: 08/30/2006	Registered
ME, MYSELF AND EYE	Reg. No: 3,195,116	United States of America	Reg Date: 01/02/2007	Registered
ME, MYSELF AND EYE	Reg. No: 4958325	Japan	Reg Date: 06/02/2006	Registered
ME, MYSELF AND EYE	Serial No: 1275797	Canada	App Date: 10/06/2005	Allowed
NEAR, FAR AND IN-BETWEEN	Reg. No: 005351961	European Community	Reg Date: 09/13/2007	Registered
NEAR, FAR AND IN-BETWEEN	Serial No: 1469067	Canada	App Date: 02/10/2010	Allowed
NEAR, FAR AND IN-BETWEEN	Serial No: 77/872,400	United States of America	App Date: 11/13/2009	Allowed - Intent to Use
OPHTHONIX	Reg. No: 2,925,566	United States of America	Reg Date: 02/08/2005	Registered
OPHTHONIX	Reg. No: 2,995,471	United States of America	Reg Date: 09/13/2005	Registered
OPHTHONIX	Reg. No: 3,127,221	United States of America	Reg Date: 08/08/2006	Registered
OPHTHONIX	Reg. No: 4986367	Japan	Reg Date: 09/08/2006	Registered
OPHTHONIX	Reg. No: 55071	Switzerland	Reg Date: 10/13/2006	Registered
OPHTHONIX	Serial No: 1232818	Canada	App Date: 09/29/2004	Allowed
OPHTHONIX	Serial No: 2009084638	Japan	App Date: 11/09/2009	Filed
OPHTHONIX & DESIGN	Reg. No: 003595501	European Community	Reg Date: 05/17/2005	Registered
OPHTHONIX & DESIGN	Reg. No: 3,108,248	United States of America	Reg Date: 06/20/2006	Registered
OPHTHONIX & DESIGN	Reg. No: 3,273,499	United States of America	Reg Date: 08/07/2007	Registered
OPHTHONIX & DESIGN	Reg. No: 3,379,275	United States of America	Reg Date: 02/05/2008	Registered
POWERED BY IPRINT	Reg. No: 3,866,649	United States of America	Reg Date: 10/26/2010	Registered
PUBLICIZE (STYLIZED)	Reg. No: 005807326	European Community	Reg Date: 09/04/2008	Registered
PUBLICIZE (STYLIZED)	Reg. No: 3,482,599	United States of America	Reg Date: 08/05/2008	Registered

Description	Serial/Application Number	Country	Registration/ Application Date	Status
PUBLICIZE (STYLIZED)	Reg. No: 5178500	Japan	Reg Date: 11/07/2008	Registered
PUBLICIZE (STYLIZED)	Reg. No: 563166	Switzerland	Reg Date: 10/09/2007	Registered
PUBLICIZE (STYLIZED)	Serial No: 1342141	Canada	App Date: 04/04/2007	Allowed
VISION OPTIMIZED. NOT COMPROMISED.	Reg. No: 004032157	European Community	Reg Date: 11/22/2005	Registered
WOW	Reg. No: 006882691	European Community	Reg Date: 01/15/2009	Registered
WOW	Reg. No: 3,858,700	United States of America	Reg Date: 10/12/2010	Registered
WOW	Serial No: 009647082	European Community	App Date: 01/10/2011	Filed
WOW	Serial No: 1393781	Canada	App Date: 05/01/2008	Allowed
WOW	Serial No: 1510547	Canada	App Date: 01/10/2011	Filed
WOW	Serial No: 2011001085	Japan	App Date: 01/11/2011	Filed
WOW	Serial No: 85/081,848	United States of America	App Date: 07/09/2010	Filed - Intent to Use
Z VIEW	Reg. No: 003595345	European Community	Reg Date: 08/11/2005	Registered
Z VIEW	Reg. No: 3,199,308	United States of America	Reg Date: 01/16/2007	Registered
Z VIEW	Reg. No: 4986368	Japan	Reg Date: 09/08/2006	Registered
Z VIEW	Reg. No: 551072	Switzerland	Reg Date: 10/13/2006	Registered
Z VIEW	Reg. No: TMA724,559	Canada	Reg Date: 09/25/2008	Registered
Z VIEW	Serial No: 2009084639	Japan	App Date: 11/09/2009	Filed
Z VIEW (STYLIZED)	Reg. No: 004680849	European Community	Reg Date: 11/15/2006	Registered
Z VIEW (STYLIZED)	Reg. No: 3,319,911	United States of America	Reg Date: 10/23/2007	Registered
Z VIEW (STYLIZED)	Reg. No: 5009633	Japan	Reg Date: 12/08/2006	Registered
Z VIEW (STYLIZED)	Serial No: 1275793	Canada	App Date: 10/06/2005	Allowed

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